

	Hit s	Search Text	DBs
26	2	(non\$4ionic\$4surfactant same (polyoxyethylene or (polyoxyalkylene near8 ether) or (sorbitan near9 fatty near9 acid) or (glycerol near9 fatty near9 ester) or (phenol near9 ethoxylate) or alkoxylate or amide or (alcohol near16 ethoxylate) or (ethylene near4 diamine))) and ((resist or photoresist or photocurable or composition or chemical)) and (linear near4 alcohol)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB
27	4	"430"/\$.ccls. and ((non\$4ionic\$4surfactant or polyoxyethylene or (polyoxyalkylene near8 ether) or (sorbitan near9 fatty near9 acid) or (glycerol near9 fatty near9 ester) or (phenol near9 ethoxylate) or alkoxylate or amide or alcohol or (ethylene near4 diamine)) near12 (apply\$4 or coat\$4 or form\$4 or deposit\$4 or treat\$4 or rins\$5) near8 (resist or photoresist) near9 (pattern or structure)) and ((third or second or thicken\$4 or swell\$4 or enhanc\$4) near9 (resist near4 pattern) near9 (film or coat\$4 or layer or laminate)) and (linear near12 alcohol)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB

	Hit s	Search Text	DBs
28	15	(non\$4ionic\$4surfactant same (polyoxyethylene or (phenol near12 ethoxylate) or (polyoxyalkylene near8 ether) or (sorbitan near9 fatty near9 acid) or (glycerol near9 fatty near9 ester) or (phenol near9 ethoxylate) or alkoxylate or amide or (alcohol near16 ethoxylate) or (ethylene near4 diamine))) and ((resist or photoresist or photocurable or composition or chemical))	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB